



Package: Flanged Ceramic, 2-pin, RF400-2

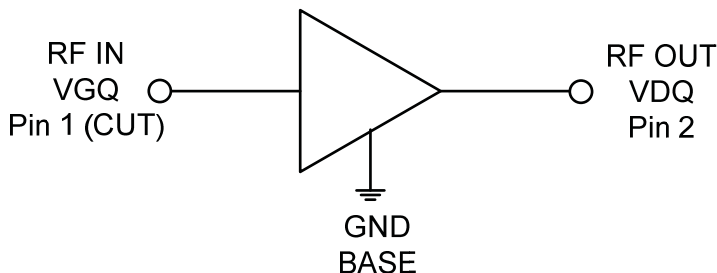


## Features

- Advanced GaN HEMT Technology
- Typical Peak Modulated Power >120W
- Advanced Heat-Sink Technology
- Single Circuit for 865MHz To 960MHz
- 48V Operation Typical Performance:
  - $P_{OUT} = 44\text{dBm}$
  - Gain = 20dB
  - Drain Efficiency = 38%
  - ACP = -33.5dBc
  - Linearizable to -55dBc with DPD
- -25°C To 85°C Operating Temperature
- Optimized for Video Bandwidth and Minimized Memory Effects
- RF Tested for 3GPP Performance
- RF Tested for Peak Power Using IS95
- Large Signal Models Available

## Applications

- Commercial Wireless Infrastructure
- High Efficiency Doherty
- High Efficiency Envelope Tracking



Functional Block Diagram

## Product Description

The RFG1M09090 is optimized for commercial infrastructure applications in the 700MHz to 1000MHz frequency band, ideal for WCDMA and LTE applications. Using an advanced 48V high power density Gallium Nitride (GaN) semiconductor process optimized for high peak-to-average ratio applications, these high performance amplifiers achieve high efficiency and flat gain over a broad frequency range in a single amplifier design. The RFG1M09090 is an input-matched GaN transistor packaged in an air cavity ceramic package which provides excellent thermal stability. Ease of integration is accomplished through the incorporation of simple, optimized matching networks external to the package that provide wideband gain, efficiency, and linearizable performance in a single amplifier.

## Ordering Information

RFG1M09090	700MHz to 1000MHz 90W GaN Power Amplifier
RFG1M09090PCBA-410	865MHz to 960MHz, Fully Assembled Evaluation Board

## Optimum Technology Matching® Applied

- |                                      |                                      |                                     |  |
|--------------------------------------|--------------------------------------|-------------------------------------|--|
| <input type="checkbox"/> GaAs HBT    | <input type="checkbox"/> SiGe BiCMOS | <input type="checkbox"/> GaAs pHEMT | <input checked="" type="checkbox"/> GaN HEMT |
| <input type="checkbox"/> GaAs MESFET | <input type="checkbox"/> Si BiCMOS   | <input type="checkbox"/> Si CMOS    | <input type="checkbox"/> BiFET HBT           |
| <input type="checkbox"/> InGaP HBT   | <input type="checkbox"/> SiGe HBT    | <input type="checkbox"/> Si BJT     |  |

## Absolute Maximum Ratings

Parameter	Rating	Unit
Drain Voltage ( $V_D$ )	150	V
Gate Voltage ( $V_G$ )	-8 to +2	V
Gate Current ( $I_G$ )	105	mA
Operational Voltage	50	V
Ruggedness (VSWR)	10:1	
Storage Temperature Range	-65 to +125	°C
Operating Temperature Range ( $T_L$ )	-25 to +85	°C
Operating Junction Temperature ( $T_J$ )	200	°C
Human Body Model	Class 1A	
MTTF ( $T_J < 200$ °C, 95% Confidence Limits)*	3E + 06	Hours
Thermal Resistance, $R_{TH}$ (junction to case) measured at $T_C = 85$ °C, DC bias only)	2.7	°C/W

\*MTTF - median time to failure for wear-out failure mode (30%  $I_{DSS}$  degradation) which is determined by the technology process reliability. Refer to product qualification report for FIT (random) failure rate.

Operation of this device beyond any one of these limits may cause permanent damage. For reliable continuous operation, the device voltage and current must not exceed the maximum operating values specified in the table on page two.

Bias Conditions should also satisfy the following expression:

$$P_{DISS} < (T_J - T_C)/R_{TH} \text{ J-C and } T_C = T_{CASE}$$



**Caution!** ESD sensitive device.

Exceeding any one or a combination of the Absolute Maximum Rating conditions may cause permanent damage to the device. Extended application of Absolute Maximum Rating conditions to the device may reduce device reliability. Specified typical performance or functional operation of the device under Absolute Maximum Rating conditions is not implied.

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RFMD Green: RoHS compliant per EU Directive 2002/95/EC, halogen free per IEC 61249-2-21, < 1000ppm each of antimony trioxide in polymeric materials and red phosphorus as a flame retardant, and <2% antimony in solder.

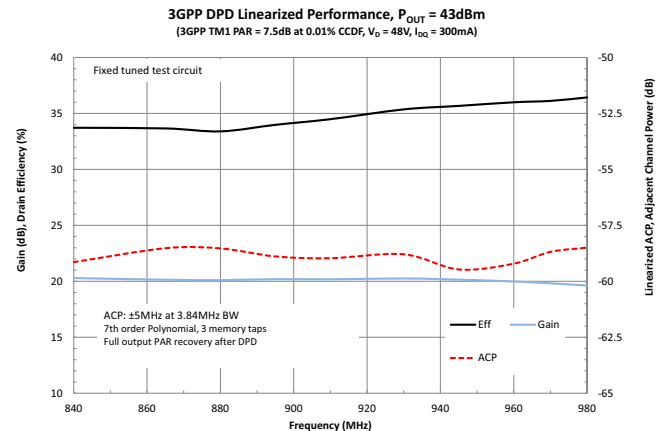
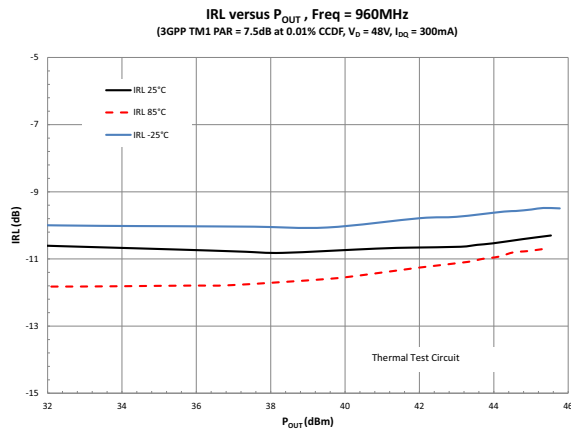
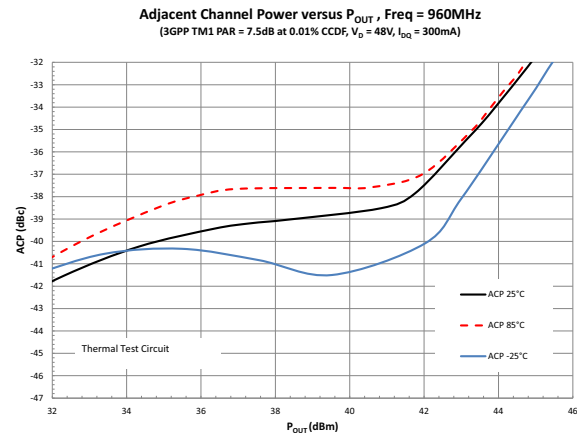
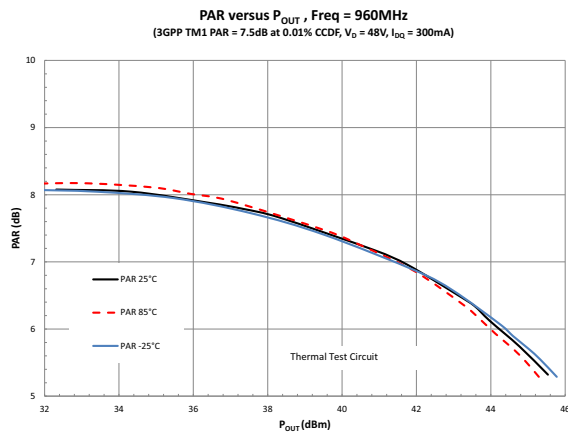
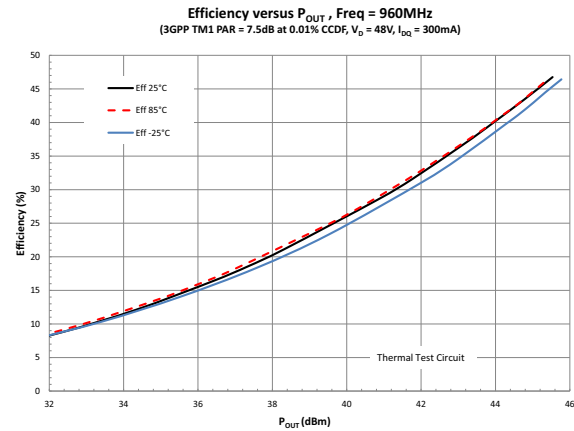
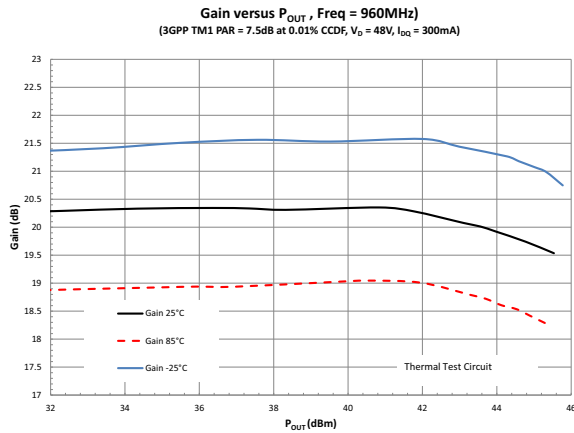
Parameter	Specification			Unit	Condition
	Min.	Typ.	Max.		
Recommended Operating Condition					
Drain Voltage (V <sub>DSQ</sub> )	28		48	V	
Gate Voltage (V <sub>GSQ</sub> )	-4.5	-3.2	-2.0	V	
Drain Bias Current		300		mA	
Frequency of Operation	700		1000	MHz	
DC Function Test					
I <sub>G</sub> (off) - Gate Leakage			2	mA	V <sub>G</sub> = -8V, V <sub>D</sub> = 0V
I <sub>D</sub> (off) - Drain Leakage			2.5	mA	V <sub>G</sub> = -8V, V <sub>D</sub> = 48V
V <sub>GS</sub> (th) - Threshold Voltage		-3.6		V	V <sub>D</sub> = 48V, I <sub>D</sub> = 14mA
V <sub>DS</sub> (on) - Drain Voltage at High Current		0.45		V	V <sub>G</sub> = 0V, I <sub>D</sub> = 1.5mA
Capacitance					
C <sub>RSS</sub>		5.4		pF	V <sub>G</sub> = -8V, V <sub>D</sub> = 0V
C <sub>ISS</sub>		77.6		pF	V <sub>G</sub> = -8V, V <sub>D</sub> = 0V
C <sub>OSS</sub>		15.1		pF	V <sub>G</sub> = -8V, V <sub>D</sub> = 0V

Parameter	Specification			Unit	Condition
	Min.	Typ.	Max.		
<b>RF Functional Test</b>					[1], [2]
$V_{GS} (Q)$		-3.2		V	$V_D = 48V, I_D = 300mA$
Gain	18	19.8		dB	3GPP (TM1, 7.5dB PAR at 0.01% CCDF), $P_{OUT} = 44dBm, f = 960MHz$
	17	19		dB	IS95 (9-channel model, 9.8dB PAR at 0.01% CCDF), $P_{OUT} = 45dBm, f = 960MHz$
Drain Efficiency	38	39		%	3GPP (TM1, 7.5dB PAR at 0.01% CCDF), $P_{OUT} = 44dBm, f = 960MHz$
	44	46.5		%	IS95 (9-channel model, 9.8dB PAR at 0.01% CCDF), $P_{OUT} = 45dBm, f = 960MHz$
Input Return Loss		-11	-8	dB	3GPP (TM1, 7.5dB PAR at 0.01% CCDF), $P_{OUT} = 44dBm, f = 960MHz$
Output PAR (CCDF at 0.01%)	5.8	6.1		dB	3GPP (TM1, 7.5dB PAR at 0.01% CCDF), $P_{OUT} = 44dBm, f = 960MHz$
	5	5.8		dB	IS95 (9-channel model, 9.8dB PAR at 0.01% CCDF), $P_{OUT} = 45dBm, f = 960MHz$
Adjacent Channel Power		-33.5	-28.5	dBc	3GPP (TM1, 7.5dB PAR at 0.01% CCDF), $P_{OUT} = 44dBm, f = 960MHz$

[1] Test Conditions:  $V_{DSQ} = 48V, I_{DQ} = 300mA, T = 25^\circ C$

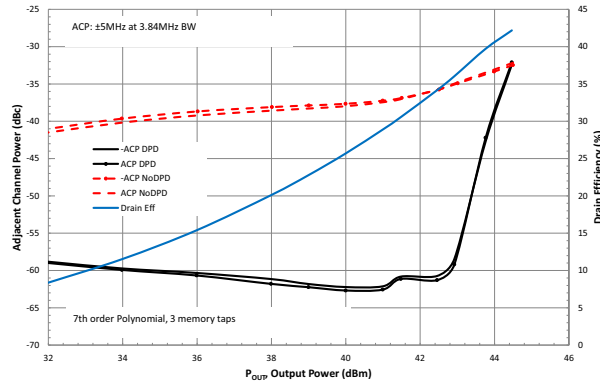
[2] Performance in a standard tuned test fixture

## Typical Performance in Standard Fixed Tuned Test Fixture (T = 25°C, unless noted)

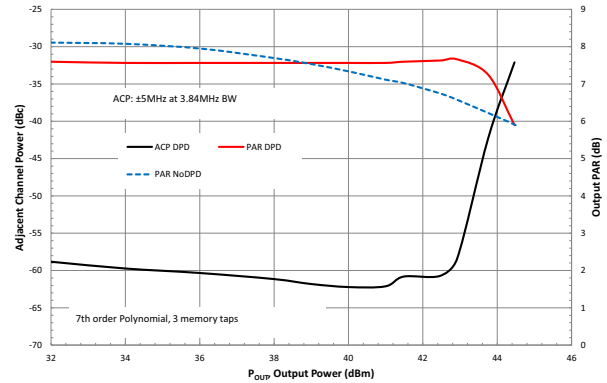


## Typical Performance in Standard Fixed Tuned Test Fixture (T = 25°C, unless noted)

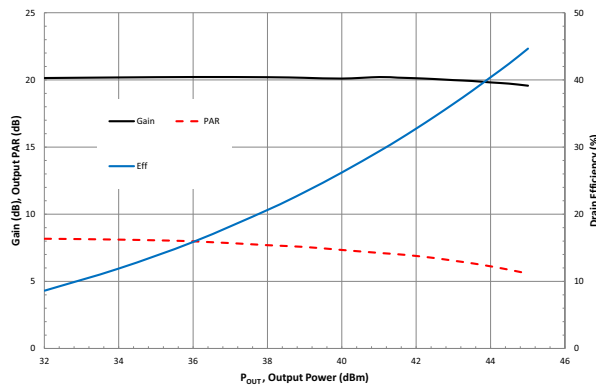
3GPP DPD Performance versus  $P_{OUT}$ , f = 960MHz  
(3GPP TM1 PAR = 7.5dB at 0.01% CCDF,  $V_D = 48V$ ,  $I_{DQ} = 300mA$ )



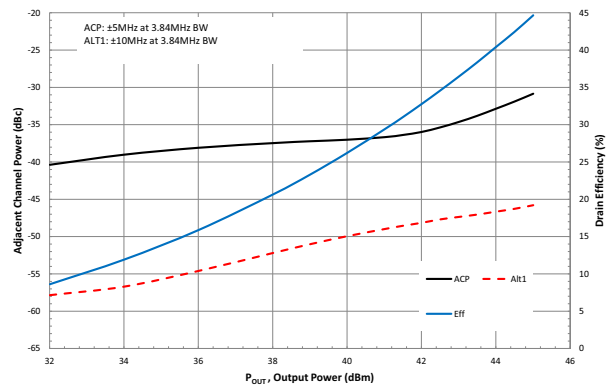
3GPP DPD Performance versus  $P_{OUT}$ , f = 960MHz  
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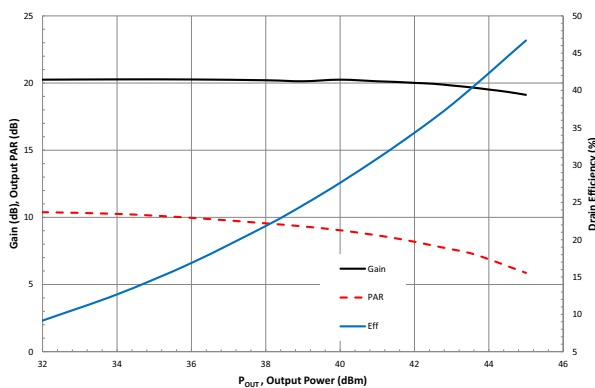
3GPP Performance versus  $P_{OUT}$ , f = 960MHz  
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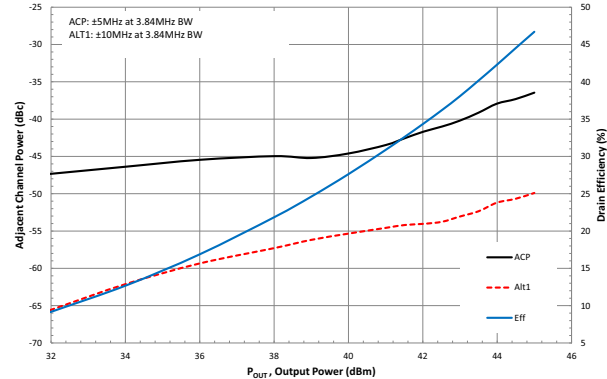
3GPP Performance versus  $P_{OUT}$ , f = 960MHz  
(3GPP TM1 PAR = 7.5dB at 0.01% CCDF,  $V_D = 48V$ ,  $I_{DQ} = 300mA$ )



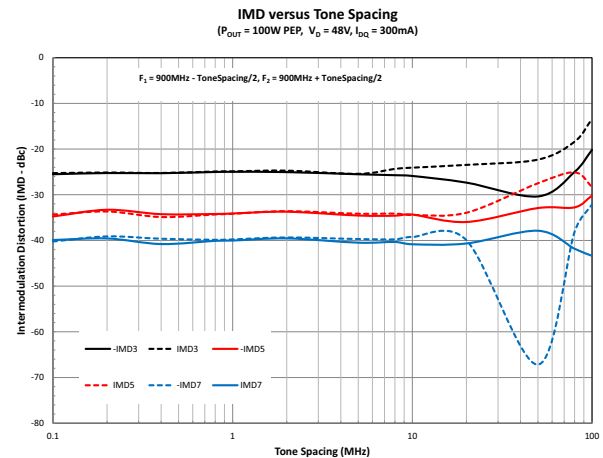
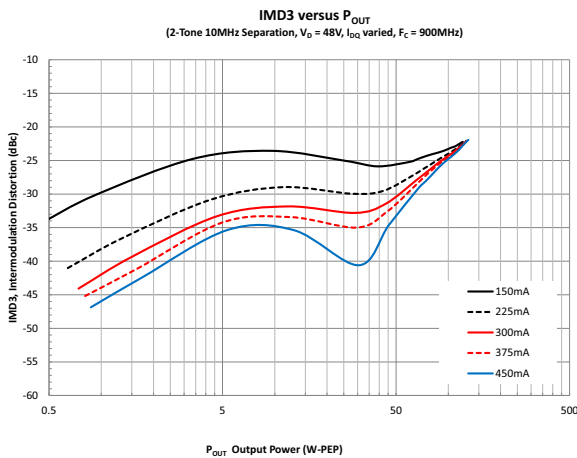
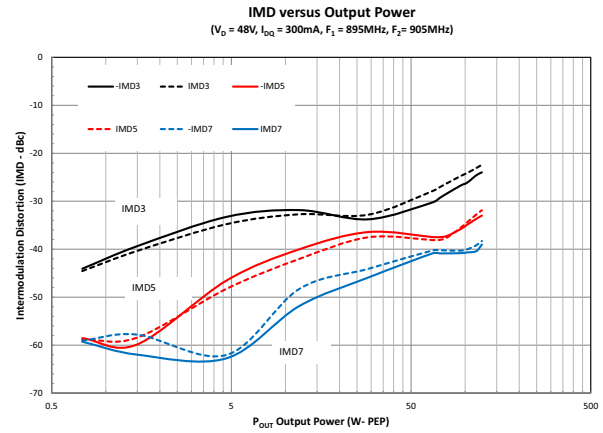
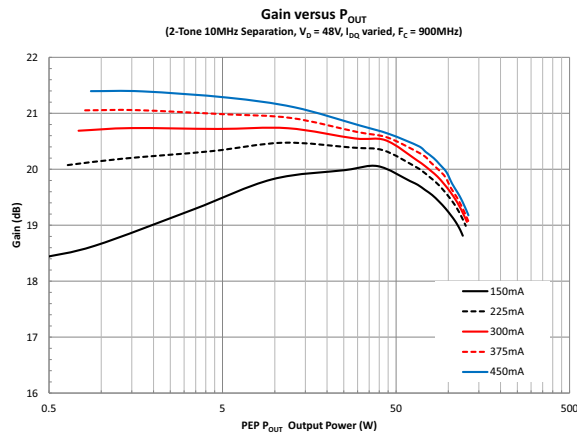
IS95 Performance versus  $P_{OUT}$ , f = 960MHz  
(IS95 9 Channel 9.8dB at 0.01% CCDF,  $V_D = 48V$ ,  $I_{DQ} = 300mA$ )



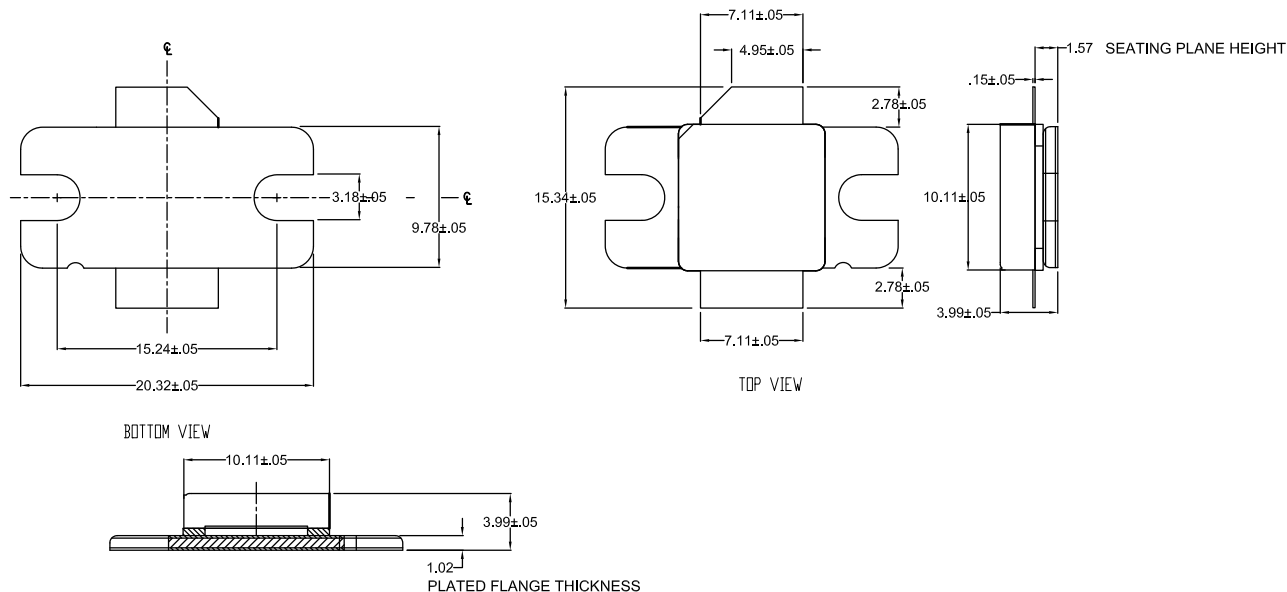
IS95 Performance versus  $P_{OUT}$ , f = 960MHz  
(IS95 9 Channel 9.8dB at 0.01% CCDF,  $V_D = 48V$ ,  $I_{DQ} = 300mA$ )



## Typical Performance in Standard Fixed Tuned Test Fixture (T = 25°C, unless noted)



**Package Drawing**  
(All dimensions in mm)



Package Style: Flanged Ceramic

**Pin Names and Descriptions**

Pin	Name	Description
<b>1</b>	<b>RF IN VGQ</b>	Gate - $V_{GQ}$ RF Input
<b>2</b>	<b>RF OUT VDQ</b>	Drain - $V_{DQ}$ RF Output
<b>3</b>	<b>GND BASE</b>	Source - Ground Base



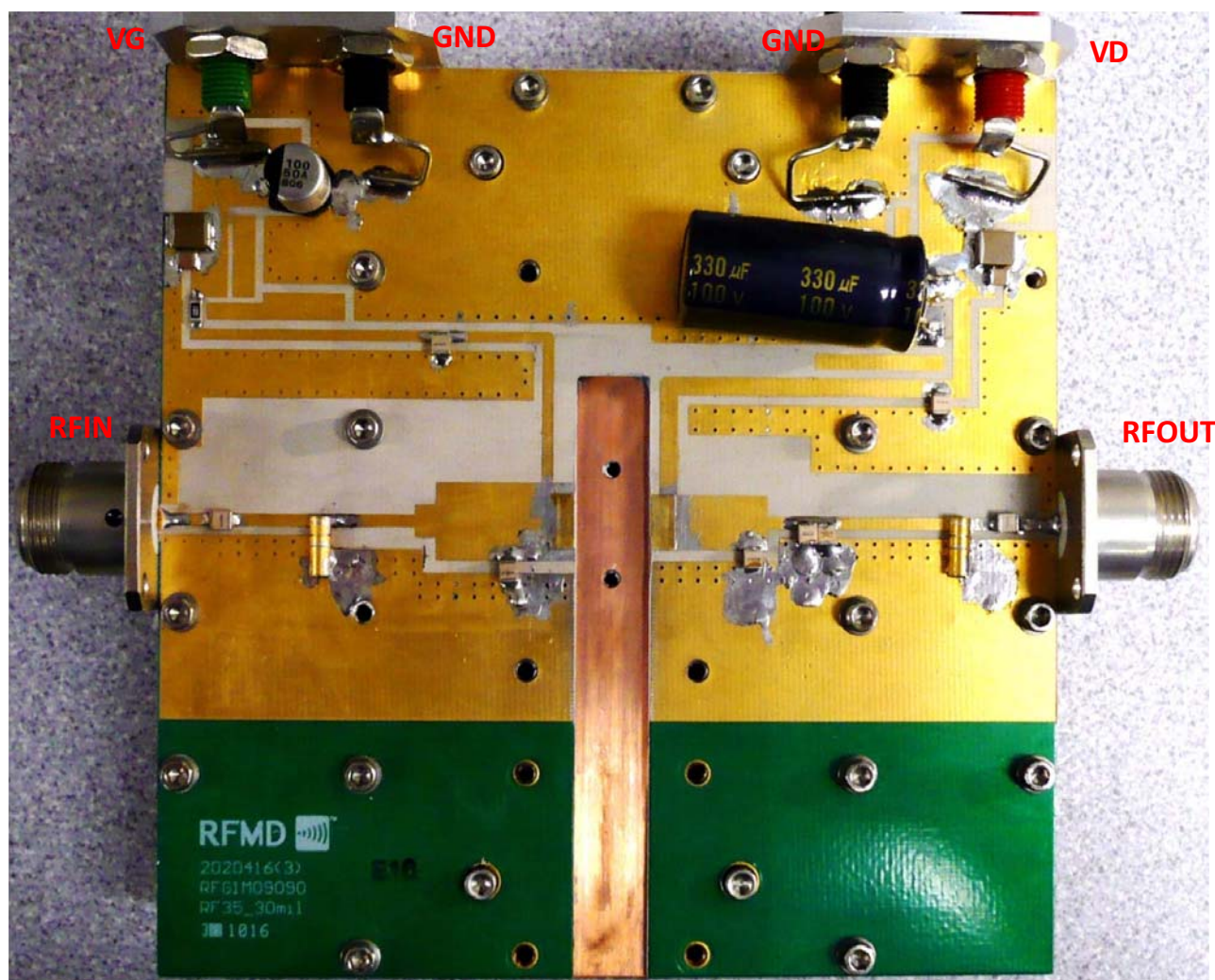
## Bias Instructions for RFG1M09090 Evaluation Board

This is ESD sensitive material; please use proper ESD precautions when handling devices or the evaluation board.

The evaluation board requires additional external fan cooling.

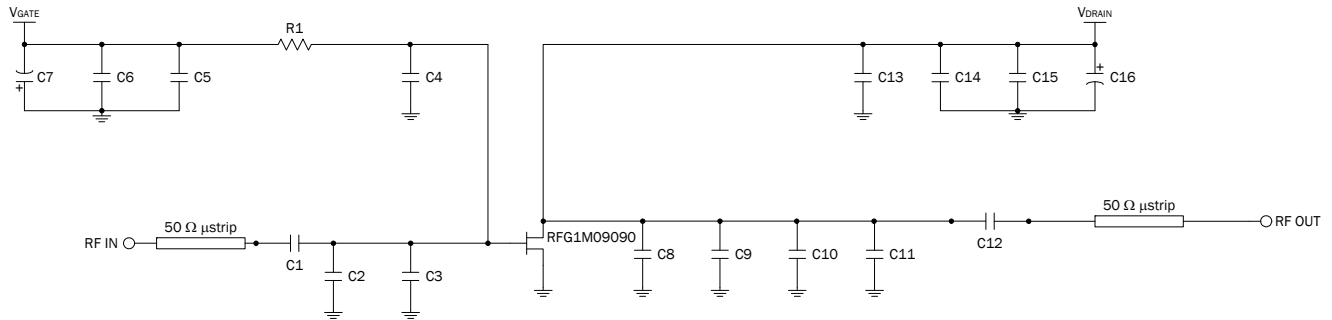
Connect all supplies before powering up the evaluation board.

1. Connect RF cables at RFIN and RFOUT.
2. Connect ground to the ground supply terminal, and ensure that both the VG and VD grounds are also connected to this ground terminal.
3. Apply -5V to VG.
4. Apply 48V to VD.
5. Increase  $V_G$  until drain current reaches 300mA or desired bias point.
6. Turn on the RF input.





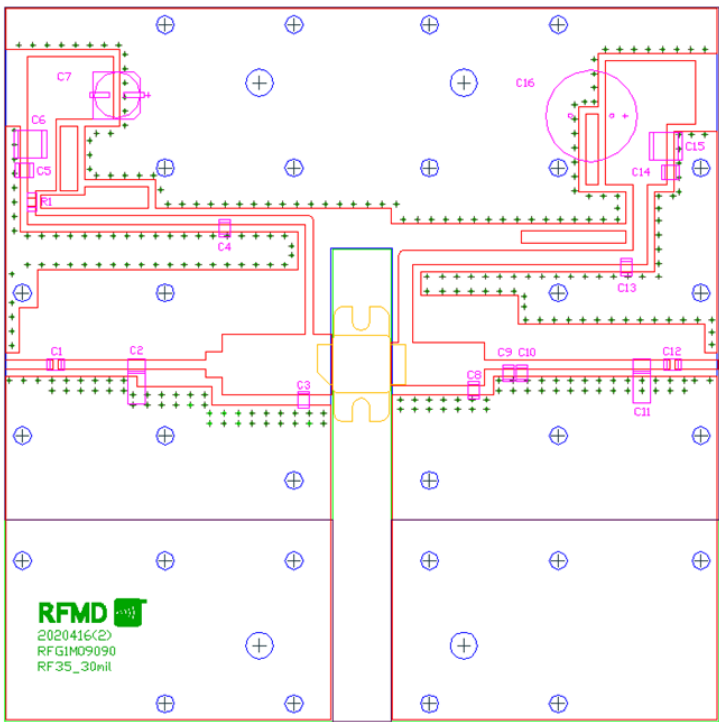
## Evaluation Board Schematic



## Evaluation Board Bill of Materials (BOM)

Component	Value	Manufacturer	Part Number
C1, C4, C12, C13	56pF	ATC	ATC100B560JT
C2, C11	0.6pF to 4.5pF	Johanson	27271SL
C3, C10	1.8pF	ATC	ATC100B1R8BT
C5, C14	0.1μF	Murata	GRM32NR72A104KA01L
C6, C15	4.7μF	Murata	GRM55ER72A475KA01L
C7	100μF	Panasonic	ECE-V1HA101UP
C8	5.6pF	ATC	ATC100B5R6CT
C9	10pF	ATC	ATC100B100JT
C16	330 μF	Panasonic	EEU-FC2A331
R1	10Ω	Panasonic	ERJ-8GEYJ100V

Evaluation Board Layout

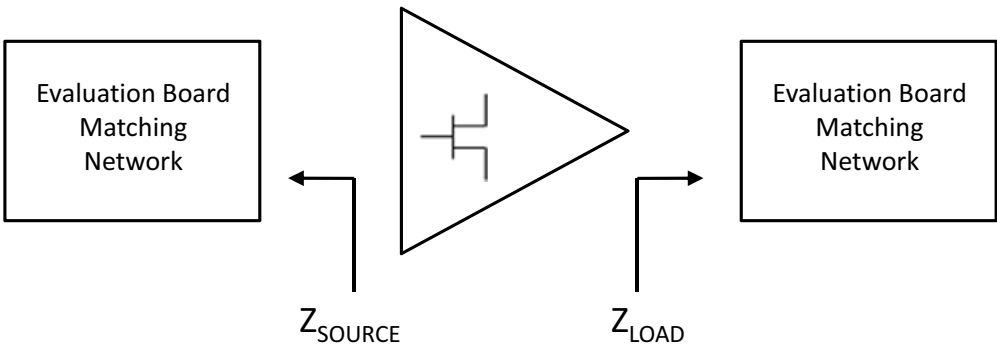


Device Impedances

Frequency (MHz)	Z Source ( $\Omega$ )	Z Load ( $\Omega$ )
700*	3.9 - j8.0	8.0 + j3.8
865	10.0 - j2.9	8.4 + j4.3
895	10.0 - j2.1	8.7 + j4.2
930	11.4 - j1.4	8.7 + j4.3
960	12.4 - j1.4	8.6 + j4.5

Note: Device impedances reported are the measured evaluation board impedances chosen for a tradeoff of efficiency, peak power, and linearity performance across the entire frequency bandwidth.

\*700MHz impedances are based on loadpull measurements; all other impedances are the measured evaluation board impedances



### Device Handling/Environmental Conditions

RFMD does not recommend operating this device with typical drain voltage applied and the gate pinched off in a high humidity, high temperature environment.

GaN HEMT devices are ESD sensitive materials. Please use proper ESD precautions when handling devices or evaluation boards.

### GaN HEMT Capacitances

The physical structure of the GaN HEMT results in three terminal capacitors similar to other FET technologies. These capacitances exist across all three terminals of the device. The physical manufactured characteristics of the device determine the value of the  $C_{DS}$  (drain to source),  $C_{GS}$  (gate to source) and  $C_{GD}$  (gate to drain). These capacitances change value as the terminal voltages are varied. RFMD presents the three terminal capacitances measured with the gate pinched off ( $V_{GS} = -8V$ ) and zero volts applied to the drain. During the measurement process, the parasitic capacitances of the package that holds the amplifier is removed through a calibration step. Any internal matching is included in the terminal capacitance measurements. The capacitance values presented in the typical characteristics table of the device represent the measured input ( $C_{ISS}$ ), output ( $C_{OSS}$ ), and reverse ( $C_{RSS}$ ) capacitance at the stated bias voltages. The relationship to three terminal capacitances is as follows:

$$C_{ISS} = C_{GD} + C_{GS}$$

$$C_{OSS} = C_{GD} + C_{DS}$$

$$C_{RSS} = C_{GD}$$

### DC Bias

The GaN HEMT device is a depletion mode high electron mobility transistor (HEMT). At zero volts  $V_{GS}$  the drain of the device is saturated and uncontrolled drain current will destroy the transistor. The gate voltage must be taken to a potential lower than the source voltage to pinch off the device prior to applying the drain voltage, taking care not to exceed the gate voltage maximum limits. RFMD recommends applying  $V_{GS} = -5V$  before applying any  $V_{DS}$ .

RF Power transistor performance capabilities are determined by the applied quiescent drain current. This drain current can be adjusted to trade off power, linearity, and efficiency characteristics of the device. The recommended quiescent drain current ( $I_{DQ}$ ) shown in the RF typical performance table is chosen to best represent the operational characteristics for this device, considering manufacturing variations and expected performance. The user may choose alternate conditions for biasing this device based on performance tradeoffs.

### Mounting and Thermal Considerations

The thermal resistance provided as  $R_{TH}$  (junction to case) represents only the packaged device thermal characteristics. This is measured using IR microscopy capturing the device under test temperature at the hottest spot of the die. At the same time, the package temperature is measured using a thermocouple touching the backside of the die embedded in the device heatsink but sized to prevent the measurement system from impacting the results. Knowing the dissipated power at the time of the measurement, the thermal resistance is calculated.

In order to achieve the advertised MTTF, proper heat removal must be considered to maintain the junction at or below the maximum of 200°C. Proper thermal design includes consideration of ambient temperature and the thermal resistance from ambient to the back of the package including heatsinking systems and air flow mechanisms. Incorporating the dissipated DC power, it is possible to calculate the junction temperature of the device.